

L Number	Hits	Search Text	DB	Time stamp
-	361	349/122.ccls.	USPAT	2003/03/22 13:21
-	2	chung.xa. and parker.xp. and international.as.	USPAT	2003/03/21 17:19
-	44	chung.xa. and parker.xp.	USPAT	2003/03/21 17:20
-	49	349/\$.ccls. and chung.xa.	USPAT	2003/03/21 17:21
-	594	349/106.ccls.	USPAT	2003/03/21 17:21
-	28	349/129-130.ccls. and slit	USPAT	2003/03/21 19:06
-	25	349/\$.ccls. and substrate near2 slit	USPAT	2003/03/21 19:11
-	594	349/106.ccls.	USPAT	2003/03/21 19:23
-	173	349/130.ccls.	USPAT	2003/03/21 19:24
-	182	349/\$.ccls. and multi-domain	USPAT	2003/03/21 19:33
-	361	349/122.ccls.	USPAT	2003/03/21 19:37
-	594	349/106.ccls.	USPAT	2003/03/21 19:45
-	6	349/130.ccls. and samsung.as.	USPAT	2003/03/21 19:47
-	270	349/141.ccls.	USPAT	2003/03/21 20:35
-	11	349/141.ccls. and samsung.as.	USPAT	2003/03/21 20:07
-	0	349/141.ccls. and samsung.as. and "vertical alignment"	USPAT	2003/03/21 20:05
-	0	349/141.ccls. and samsung.as. and homeotropic	USPAT	2003/03/21 20:06
-	4	349/141.ccls. and samsung.as. and vertical	USPAT	2003/03/21 20:06
-	14	349/141.ccls. and "vertically aligned"	USPAT	2003/03/21 20:16
-	36	349/141.ccls. and ("vertically aligned" or homeotropic)	USPAT	2003/03/21 20:08
-	26	349/141.ccls. and homeotropic	USPAT	2003/03/21 20:09
-	49	349/160.ccls.	USPAT	2003/03/21 20:20
-	284	349/172.ccls.	USPAT	2003/03/21 20:20
-	38	349/141.ccls. and hyundai.as.	USPAT	2003/03/21 21:29
-	18	349/141.ccls. and hyundai.as. and (vertical or homeotropic)	USPAT	2003/03/21 21:23
-	5	349/141.ccls. and hyundai.as. and parker.xp.	USPAT	2003/03/21 21:23
-	8	349/141.ccls. and chung.xa.	USPAT	2003/03/21 21:29
-	1	"6052168".PN.	USPAT	2003/03/21 21:30
-	1	5691791.pn.	USPAT	2003/03/22 13:21
-	3	4456336.pn. 5220444.pn. 6008875.pn.	USPAT	2003/03/22 13:36
-	106	438/30.ccls. and (dry-etching or "dry etching")	USPAT	2003/03/22 14:05
-	36	349/113.ccls. and (dry-etching or "dry etching")	USPAT	2003/03/22 14:21
-	1452	"liquid crystal display" and (dry-etching or "dry etching")	USPAT	2003/03/22 14:22
-	137	"liquid crystal display" and (dry-etching or "dry etching") and (reflector or "reflective electrode")	USPAT	2003/03/22 14:34
-	1		USPAT	2003/03/22 14:25
-	1		USPAT	2003/03/22 14:25
-	1		USPAT	2003/03/22 14:25
-	1		USPAT	2003/03/22 14:29
-	1		USPAT	2003/03/22 14:30
-	1		USPAT	2003/03/22 14:30
-	1		USPAT	2003/03/22 14:30
-	1		USPAT	2003/03/22 14:30
-	1		USPAT	2003/03/22 14:30
-	1		USPAT	2003/03/22 14:30
-	12	((("5805252") or ("5734455") or ("5663020") or ("5619356") or ("5610741") or ("5526149") or ("5500750") or ("5408345") or ("5204765") or ("4519678") or ("4431272") or ("4106859")).PN.	USPAT	2003/03/22 20:29
-	1	4904056.pn.	USPAT	2003/03/22 21:06
-	27	349/113.ccls. and (dry-etching or "dry etching") and mask	USPAT	2003/03/22 21:15
-	1		USPAT	2003/03/22 21:07
-	1		USPAT	2003/03/22 21:07
-	20	349/113.ccls. and nec.as.	USPAT	2003/03/22 21:35
-	66	"liquid crystal display" and (dry-etching or "dry etching") and nec.as.	USPAT	2003/03/22 21:21

-	3	"liquid crystal display" and (dry-etching or "dry etching") and nec.as. and (reflector or "reflective electrode")	USPAT	2003/03/22 21:22
-	1	6521525.pn.	USPAT	2003/03/22 21:26
-	16688	dry-etching or "dry etching"	USPAT	2003/03/22 21:26
-	1606	(dry-etching or "dry etching") and ("liquid crystal display" or lcd)	USPAT	2003/03/22 21:26
-	300	(dry-etching or "dry etching") and ("liquid crystal display" or lcd) and (reflective or reflector)	USPAT	2003/03/22 21:31
-	1	5691791.pn.	USPAT	2003/03/22 22:02
-	8	349/113.ccls. and nec.as. and (dry-etching or "dry etching")	USPAT	2003/03/22 21:36
-	8	349/113.ccls. and nec.as. and (dry-etch\$ or dry)	USPAT	2003/03/22 21:37
-	1	6292241.pn.	USPAT	2003/03/22 21:38
-	63213	349/\$.ccls. or 438/\$.ccls.	USPAT	2003/03/22 21:38
-	15487	(349/\$.ccls. or 438/\$.ccls.) and dry	USPAT	2003/03/22 21:38
-	3325	(349/\$.ccls. or 438/\$.ccls.) and dry and reflect\$	USPAT	2003/03/22 21:39
-	137	438/30.ccls. and dry	USPAT	2003/03/22 21:40
-	1	6222600.pn.	USPAT	2003/03/22 21:41
-	20	349/\$.ccls. and emboss	USPAT	2003/03/22 21:42
-	24	438/\$.ccls. and emboss	USPAT	2003/03/22 21:42
-	0	("dry etching" or dry-etching) near2 "passivation layer" and "reflective electrode"	USPAT	2003/03/22 21:47
-	32	("dry etching" or dry-etching) and "reflective electrode"	USPAT	2003/03/22 21:48
-	1	5408345.pn.	USPAT	2003/03/22 23:22
-	29	349/\$.ccls. and "uneven surface" and ("dry etching" or dry-etching or dry-etched or "dry etched")	USPAT	2003/03/22 22:05
-	0	349/\$.ccls. and "uneven surface" near4 ("dry etching" or dry-etching or dry-etched or "dry etched")	USPAT	2003/03/22 22:06
-	1	438/\$.ccls. and "uneven surface" near4 ("dry etching" or dry-etching or dry-etched or "dry etched")	USPAT	2003/03/22 22:08
-	60	349/113.ccls. and dry	USPAT	2003/03/22 22:22
-	37	349/173.ccls.	USPAT	2003/03/22 22:10
-	1		USPAT	2003/03/22 22:16
-	1		USPAT	2003/03/22 22:16
-	1		USPAT	2003/03/22 22:16
-	1		USPAT	2003/03/22 22:17
-	1		USPAT	2003/03/22 22:17
-	1		USPAT	2003/03/22 22:18
-	1	4431272.pn.	USPAT	2003/03/22 22:29
-	1	6061112.pn.	USPAT	2003/03/22 22:29
-	1	5559617.pn.	USPAT	2003/03/22 23:22